The Journal of Technology Studies

All this fosters a personal comment that it is a great boost to a predecessor’s ego to be succeeded by a person with enormous energy, extraordinary accomplishments, and enviable talent and that it all bodes well for The Journal of Technology Studies and for Epsilon Pi Tau.

Loyal readers will notice the change very quickly. It begins on the inside front cover and signals what this observer is pleased to define as an appropriate and timely reach for the next level. The signs are good that the “next level” will be achieved because of the impressive talents, clearly supported by his credentials, of Dr. Dennis Cheek. With this issue, he phases in as co-editor of issue Number 2. The inside front cover changes and the Guidelines for Authors that are included in this volume prepare for his assumption of full editorial responsibilities for the 2004 issues and beyond. Editing the journal is one of the major responsibilities he undertakes and those were summarized in the last issue of The Epsilon Pi Tau Preceptor (“Dennis Cheek Accepts,” 2003), parts of which are related here:

The Epsilon Pi Tau Board of Directors announced that Dr. Dennis W. Cheek accepted the appointment as Associate Executive Director for Information and Communication (I&C). The board has expressed great pleasure in welcoming a person with his extensive experience and qualifications to the leadership team, all of whom volunteer their services to Epsilon Pi Tau. The Associate Executive Director for Information and Communication is one of three Associates. The two others are: for Community and Technical Colleges, and for International Affairs. These three report to the Executive Director and, with him, comprise Epsilon Pi Tau’s executive staff.

The responsibilities of the position are critical to accomplishing the honor society’s vision of superior member services and excellence in publications and communications. In that regard, Cheek will be responsible for the conduct of all of Epsilon Pi Tau’s current I&C services and for developing and implementing revised or new I&C policies that will improve member services and other internal and external efforts. Currently, the primary I&C vehicles are The Journal of Technology Studies, The Epsilon Pi Tau Preceptor, and the honor society’s web site. In time, Cheek may implement additional vehicles or modify existing ones.

Cheek has started his work on the major project of implementing a new Epsilon Pi Tau web site for which templates and services will be provided by Affinscape, a company that has extensive experience in providing web site services to organizations like Epsilon Pi Tau. In 2004 he will assume Editor responsibilities for The Journal of Technology Studies that he is already co-editing.

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Only highlights of Cheek’s much appreciated and valued experience can be communicated in this space.

Dr. Cheek is Vice President for Venture Philanthropy Innovations and Managing Director, Templeton Venture Philanthropy Associates, John Templeton Foundation in Radnor, Pennsylvania. He has 20 years of administrative and supervisory experience at school, district, state, national, and international levels. He has managed large assessment, curriculum development, teacher enhancement, accountability, and telecommunications projects, working with teachers, administrators, scientists, engineers, university faculty, corporations, and nonprofit organizations from across the sociopolitical spectrum. He has taught elementary through doctoral students in the U.S., Great Britain, and Germany over 25 years and conducted numerous preservice and in-service workshops in science, social studies, assessment, curriculum development, and science, technology & society studies. He has also served as an advisor to numerous federal and state agencies and task forces, scientific and technical associations, and consultant to educational publishers and corporations. As an author, contributor, or editor he has produced more than 475 publications and multimedia products in education, science & technology, the social sciences, and religion. He has served on the editorial or manuscript review boards of six journals and as a faculty or staff member at six colleges or universities. As part of these experiences he has been a contributor to successful grant proposals totaling more than $30 million. His extensive travel program has taken him to 40 nations on four continents.

Dennis Cheek accepts appointment to executive staff. (2003, Fall). The Epsilon Pi Tau Preceptor, 21(2), 13.

References

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Editor’s Pages

A New Editor

Jerry Streichler

References

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